A. Authors, Institutions, Overview

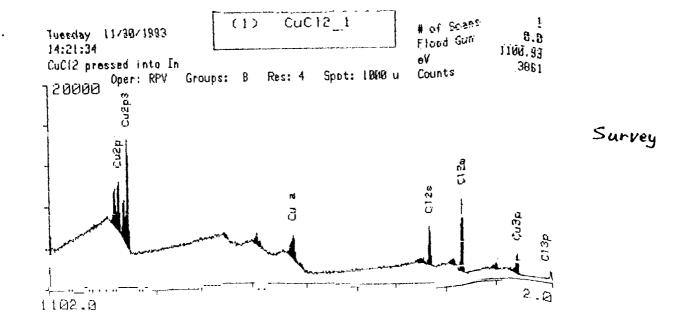
A. Authors, Institutions, Overview

Cucleby	.x <i>P</i> s	- -
	tions, and Locations (city, state, Jet Propulsion L. Sque 2. California Institui	province, or country) - List authors and affiliations, in order aboratory appearance in SSS. te of Technology Pasadena CA 9/109-5
Author	Institution	location
measure	ement procedures, and significance of t	the specimens and spectra, such as specimen material, he research. The abstract will be reprinted verbatim.
X-rayp	ement procedures, and significance of the hotoemission measurem	he research. The abstract will be reprinted verbatim.
X-ray p presented,	ement procedures, and significance of the hotoemission measurem XPS st udies of C	he research. The abstract will be reprinted verbatim. nents of high purity Cu Cl2 are u compounds in this laboratory
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X-ray p presented, ha vebeen n chemically.	ement procedures, and significance of the toemission measurement of the second street of the new etchedhigh temperatures.	he research. The abstract will be reprinted verbatim. nents of high purity Cu Cl2 are -u compounds in this laboratory ed to ident ify species on
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X-ray p presented, ha vebeen n chemically.	ement procedures, and significance of the toemission measurement of the second street of the new etchedhigh temperatures.	he research. The abstract will be reprinted verbatim. nents of high purity Cu Cl2 are Lu compounds in this laboratory ed to ident ify species on

	spectroscopy, oxidation, corrosion, surface segregation. Be selective, but thorough. X-ray photoemission copper (II) chloride, copper compounds
10.	Spectra Category - Check the suggested category of the dots record: Technical, Comparison, or Reference (see the overview of instructions for definitions). The editors may suggest on alternate category, based on the recommendations of referees.
	☐ Technical
111.	References — list citations to articles related to the doto record using the style of J. Vat. Sci. Technol. 1. R. P. Vasauez M. C. Foote, and B. D. Hunt. J. Apol. Phys.
	1. R.P. Vasquez, M.C. Foote, and B.D. Hunt, J. Appl. Phys. 66, 486 6 (1989).
	2. R. W. G. Wyckoff Crystal Structures, 2nd eel. (Wiley, New Yo
	1963), Vol. 1, p. 345.
112	Acknowledgements
,	This work was supported by NASA/CACT and BMDC/IST.
	<u> </u>

A Authors, Institutions, Overview

. SURFACE SCIENCE SPECTRA



SURFACE COMPOSITION TABLE CuC12_1
CuC12 pressed into In

	<i>cot-I-'</i> ' d Gun						Area	Relative Area	Atom %
0.0.7	00)5.0	4 0 0	-4.24	0 7/8	1	137.5	45423	500575	33.91
= -	9?)5.2 198.91				1	137, s	21750	975502	66. 09

(e.g. see Ref. 1).

A. Authors, Institutions, Overview

2.	Authors, Institutions, and		or country) — List authors and affiliations, in order of
	Richard P. Vasquez	Jet Propulsion Laboratory Colifornia Institute of Tec	oppeoronce in SSS. hadogy Pasadena, CA 91109-809
	Author	Institution	location
	Author	Institution	Location
	Author		location
	Author	Institution	Location — — —
	Author	Institution	location

have been motivated by the need to identify species on chemically-etched high temperature superconductor surfaces

A. Authors, Institutions, Overview

	-	estions or questions from SSS edit	^	
Vásquez		Richard	<i>P.</i>	
Jet Propu	Ision Labora	atory, California I	nstitute of Technology Department	
1113111011011			•	
4800 Oa	k Grove	Drive	<u>MS 302-30</u>	6
Address, PO Box	(Mail Stop	
Pasadena	,	CA 91109-	8099 USA Country	
City	`	Stole Zip Code	Country	**
(818)354-03	359	(8/8).37.34	540	
Phone		Fox	54 <u>0 </u>	
X XPS	☐ AES	Ffor each spec	uding all calibration spectra. Complete octrum.	copy or
XD xps # of Calibration		Ffor each spec	- · · · · · · · · · · · · · · · · · · ·	copy or
		Ffor each spec	- · · · · · · · · · · · · · · · · · · ·	сору от
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# of Calibratio	on Spectra in I	Ffor each specific points and specific points and specific points are considered as a specific will be entered.	ectra for which herd-copy publication is ords comprising large numbers of spectro into the AVS electronic database, but it	being red a, all of th may only
# of Calibratio	on Spectra in I	Ffor each specific points and the specific points of the specific po	ectra for which herd-copy publication is ords comprising large numbers of spectro	being rec a, all of th may only a Science
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# of Calibration — O # of Spectra f	on Spectra in l	Ffor each specific spectra submit N(E) data older or a spectra submit N(E) data older or a spectra submit spectra submit N(E) data olone or a spectra spectra submit N(E) data olone or a spectra submit N(E) data	ectra for which herd-copy publication is ords comprising large numbers of spectro into the AVS electronic database, but it presentative number of spectra in Surface to identify specific spectra for publication	being red a, all of the may only e Science on is give

SURFACE	SCIENCE	S PECTRA
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A. Authors, Institutions, Overview

0 9.	Key Words - List selected phrases and words to help readers search for information in the database, e.g. Auger electron spectroscopy, oxidation, corrosion, surface segregation. Be selective, but thorough. X-ray photoemission, copp er (II) chloride, copper compounds
0 10.	Spectra Category - Check the suggested category of the dots record: Technical, Comparison, or Reference (see the overview of instructions for definitions). The editors may suggest an alternate category, based on the recommendations of referees.
	☐ Technical
•	References - list citations to articles related to the data record using the style of J. Vat. Sci. Technol. 1. R.P. Vasquez, M.C. Foote, and B.D. Hunt, J. Appl. Phys. 66, 4866 (1989).
	66, 4866 (1989), 2. R. W. G. Wyckoff, Crystal Structures, 2nd ed. (Wiley, New York,
	1963), Vol. 1, p. 345.
6 12.	Acknowledgements
	This wok was supported by NASA/CACT and BMDO/IST.

B. Specimen Description

1. Host Material - Provide a generic description of the specimen, such os nylon, 606 l Al, or SiO2. For layered structures, the host material is the "bulk" substance near the surface. For instance, XPS of an ultra-thin metal film on a thick SiO2 layer on an Si substrate would be SiO2 because the XPS would not probe the Si.

Copper (II) chloride

- 2. Chemical Abstract Service (CAS) Registry #— Enter the CAS Registry number of the host materiel.

 7447-39-4
- 3. Material Designation Code and Organization Provide any alternate standard designator code specifying the host material, e.g. 1033 for carbon steel, and identify the organization that developed the designator code, e.g. AISI.

Organization

Code

- 4. Host Composition fist the principal elements present or the chemical formula, impractical, e.g. Li, P, O, or LigPOs.
 - **3.** Chemical Name Enter the full chemical name of the host material according to IUPAC conventions, e.g. for lisP04, Lithium Orthophosphate.

Copper (II) chloride

6. Specimen Manufacturer/Supplier - Provide the name of the manufacturer aria/or supplier of the host material or give a reference to how the host was made, e.g. thermally grown SiO2 on Si.

Aldrich Chemical Co.

7. Specimen Form - Give a physical description of the host, e.g. MC. OSFET, reagent, single-crystal wafer, stub from corroded fender for brand X pickup, etc.

_Powder, 99,999% purity. ______

8. Lot Number - Provide the code that identifies the production run. etc.

03806DV ______

, , ,

 $oldsymbol{\mathsf{B.}}$ Specimen Description

③ 9.		hexagonal close-packed, ar	nd/or comments such os frac a formula encoding scheme.	_
Fie	elds 10-13 refer to th	ne hostmaterial. They ar	e included to facilitat	e database searches.
0 10	. Homogeneity - Che	_		
	Homogeneous	☐ Inhomogeneous	Unknown	
0 11	. Phase — Check one th	hat best applies.		
•	🔀 Solid	🔀 Powder	☐ Liquid	☐ Gas
دا ۵	. Crystallinity – Chec	to and distillant and the		
U jiz	Single Crystal		Amorphous	Unknown Crystallinity
		7		, ,
© 13		eristics – Check one lhat best		
	Conductor	☐ Superconductor Ø Sen	niconductor 🗍 Diele	ectric Unknown
0114.	☐ Metol 🗵	Check one that best applies. Inorganic Organic Compound	-	☐ Biological ☐ Composite Moterial
© 15	• Special Material C	lasses - Check all appropriat	te boxes. No entry is needed n"as received condition" in f	if these Special Classes do not apply. If
	☐ Ceromic ☐ Glo	oss Thin Film 🎗	Powder	Coating Other
	Suggested New Class Ty	/pes		
© 16	• History and Signifi	retrieved by Apollo I)	K mission, or a discussion of	n about the specimen e.g. moon rock why the spectra were taken. Also, include esults of other analytical techniques.

B. Specimen Description

2 17. As Received Condition - Describe the physical condition of the specimen os it was supplied to the spectroscopist, e.g. as grown, point delaminating from metal stub, etc. Include the thermal and storage history of the specimen os well as physical condition.

99,999 % parity powder, se aled bottle as received from manufacturer,

2 18. Analyzed Region - Describe the specimen analyzed qualitatively, e.g. shorted FET gate, some as host material, or weld bead.

Same as h ost material

2 19. Ex Situ Preparation and Mounting — Describe specimen preparation prior to introduction into the spectrometer vacuum system, e.g. as received, washed in ethanol, scraped with a well-pickled file, etc. Also, describe the specimen mounting technique.

The specimen bottle was unsealed in the ultrahigh purity nitrogen atmosphere of a glove box which encloses the load lock area. The powder was pressed into 99.95% In foil and clipped to the sample holder.

'Q **20.** In Situ Preparation - Describe specimen preparation or treatment procedures within the spectrometer vacuum system prior to analysis, e.g. ion sputter cleaning and annealing.

None

3 21. Specimen Temperature During Analysis – Enter the temperature in Kelvin.

300 K

2 [22. Maximum Chamber Pressure During Analysis -- Enter the pressure, in Pascal (Torr = 133 Pascal).

<u>O</u>-7

3. Pre-Analysis Beam Exposures — Describe procedures and include comments on the amount of time the analyzed region was exposed to the x-ray or electron irradiation prior to the measurements for these spectra (especially important for beam-sensitive materials).

None.

24. Charge Control Conditions and Procedures --- Describe the equipment used to control charge at the specimen during measurement. Include flood gun voltages and current, target bias, the use of metal screens, etc. Also, describe the procedures used to determine the charge control.

90% transmitting fine mesh proximity Ni screen, flood gun set to minimize peak widths and asymmetry (0 eV, 950 mA filament current)

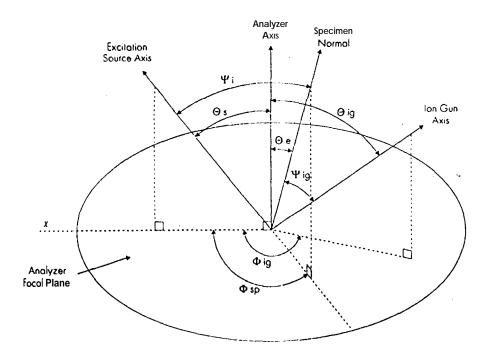
C. Overall Instrument Description

The fields in this section describe the system excitation source, the analyzer, and the ion gun used in the experiment. The equipment description is divided into parameters universal to all of the spectra in the record, such as electron spectrometer, and parameters that could vary, depending on the experimental condition, such as the energy range and increment. The universal parameters need to be described only once. However, the information in Section E for Variable Instrument Parameters must be completed and collated with the spectra described in Section F, Spectrum Parameters, for each different experimental setup.

O 1. Spectrometer Manufacturer -	- Enter the designer's name, if the instrument was custom-built, and reference a published article, if applicable.
Surface Science I	
0 2. Manufacturer Model #	
_SSX100-501	
O 3. Analyzer Type - Check one that b	pest applies. If "Other, * include a description in Field 4 below.
Cylindrical Mirror Analyzer (CMA)	Double Pass CMA
Spherical Sector Analyzer	Other
•	ns Describe any non-standard analyzer or lens used and/or any modification or enhancement made in house. If this information is not applicable to this data record, enler *N/A. *
_ <i>N/A</i>	
2 5. Acceptance Angle from Anal	yzer Axis – Enter the acceptance angle. The acceptance angle is usually420 for CMA and00 for hemispherical analyzers.
Q	degrees
1 6. Analyzer Mode - Check one that	best applies.
Constant Pass Energy (fixed analyze	er transmission) Constant RetordRatio

SI	URFACE SCIENCE	SPECTRA		C. Overall Instrument Description
2 7	. Instrument Through	out Function		ical energy dependence of the instrument throughput function ant spectral range. if "Olher," describe in Field 8 below.
] 1/E	1 /√E	23 .1	□ E .
C	Other			
4 8	. Instrument Thoughpu	it Function (Comment <i>– Elabora</i>	ate on any non-standard energy dependence.
0 9.	. Excitation Source La	abel – Check o	ne that best applies.	5
•	☐ Al Ka (non-monochron			oted) □ Mg Kα
	Other X-Ray		Electron Beom	
	Other: describe	the sou	Irce	
2 10			window.	electron shield or radiation filter in the source, e.g. 1.5 μm Al
	A u-coated mo	1 lar wina	<u> </u>	<u>-</u>
3 11	Detector Description Position S ensi		1	iraltron, dynode, multichannel resistive plate, etc.
6 12				ion gun as completely as possible if it is non-standard.
② 13	. Sputtering Current Biosed Stage	Measuremer Forod	nt Method – <i>Check</i>	k one that best applies.

The spectrometer geometry is specified with respect to a coordinate system in which the axis of the analyzer defines the polar (z) axis, and the x-y axes lie in the analyzer focal plane. The x-axis is defined by the normal projection of the excitation source axis onto the analyzer focal plane. If the analyzer and source axes are coincident, the projection of the ion gun onto the focal plane should be used as the azimuthal reference. It is presumed that all component axes intercept at a common point lying on the specimen surface.



18. Please fill in the angles (in degrees) for the submission.

	Field Name	Label	Value •
0	Emission Angle'	Θе	55
0	Incident Angle	Ψί	55
0	Source-to-Analyzer Angle	Θs	70.8
0	Specimen Azimuthal Angle	Фзр	0
•	Sputter Source Incident Angle	Ψig	<u>i</u>
0	Sputter Source Polar Angle	Θig	
8	Sputter Source Azimuthal Angle	Ф ig	

^{*} If the angle varies from one spectrum to another, enter "v."

0	19.	Angular	Geometry	Comments
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- Present any additional comments on the scattering geometry that are important to understand the measurements; e.g. the take-off angle may be important relative to the specimen structure. In later fields, several geometric factors are requested, such as roster area of ion sputtering, dimensions of excitation area, etc. If the x and y axes of the sputtered region, excited region, etc. do not coincide, describe the orientation of the various regions.

D. Calibration Information

1. Calibration Summary - Describe the calibration of your spectrometer by completing the table below. For each calibration point, enter the element and transition of the calibration peak, the energy (in eV) measured for that peak offer calibration, the measured peak width (in eV) and amplitude, and the corresponding sensitivity factor and concentration. The peak amplitude method and units for amplitude and concentration must be the same as those specified in Section L Care should be used to ensure that the correct number of significant figures is entered since the precision is a substantive aspect of calibration. The comment lines may be used to identify the calibration reference material (e.g. Au foil or Cv). If the calibration spectra are included in the data record, each calibration point should be identified with the spectrum used to obtain the data for that transition by entering the corresponding spectrum ID number (Field 1, Section F).

	ID#	Element Transition	Peak Energy	Width (FWHM)	Peek Amplitude	Sensitivity Factor	Atomic Concentration
1		Au 4fz/z	84.0	0.85	- I AMERICAN CONTRACTOR OF THE		
2		Cu 2 P3/2	932.5	- 1,1		<u>a-program</u>	
3.							
45							
5							

2. Comments

	1	Au film on Si (100) substrate (25 eV pass energy
	2	Sputter-cleaned Cu plate (cited width is for 300 ym x-ray spot,)
	3	25 eV pass energy
	4	
j	5	

E. Variable instrument Parameters

Complete a copy of this section for each set of instrument settings. For example, you might be contributing survey scans that have different energy resolutions, scan rates, etc. from a high-resolution scan of a transition's lineshape. The first field allows you to give each set of instrument settings a number for referencing to specific spectra. You need to complete a copy of this section for each different set.

O 1. Parameter Set # - Enter on identifying serial number, starting with "I" for this set of variable instrument pyrometers.

These numbers will be used in the individual data records to reference the appropriate parameter set for each spectrum described in Section 1.

Source Operating Parameters

1 2. Source Energy - Enter the characteristic energy (in eV) of the excitation source, e.g. 5,000 eV for 05 keV electron beam, 1486.6 eV for AI Kα,1253.6 eV for Mg Ka, etc.

1486.6

3. Source Strength Value and Units - Enter the strength of the excitation source and the correct corresponding units.

For XPS, this could be anode power in Watts or radiation flux density on the specimen in photons/mm² sec or, for electron beams, nanoamps or nanoamps/mm².

200 Watt s

Strength Value Units

4. Source Beam Size – List the x ond y values for the unscanned excitation source size. Choose the x and y axes 10 coincide with the manufacturer definitions. If the beam is cylindrically symmetric, x and y are equal. In other cases, such as the HP ESCA system, the beam is not cylindrically uniform. In choosing the axes, insure that x and y are orthogonal to each other and to the excitation source

1000 1000 x Volue (μm) Y Volue (μm)

5. Source RasterYesNo

retarding rotio)

E. Variable Instrument Parameters

0	6.	Source	Size	inter the x and y dimensions, in µm, of the	excilation beam at the	specimen surface.	Note that this can
				differ from the source beam size enlered	previously by <i>virtue of I</i>	beom rastering or n	on-normal angle of
				ncidence on the specimen, or both.			

<u>743</u> <u>1000</u> χ (μm)

- 7. Raster Frame Rate Give the time interval required to return the beam to a given spot on the sample (in Hertz) if the source is scanned over the sample.
- Q 8. Analyzer Resolution Enter the percent energy resolution used in the measurement on the left line if the analyzer is operated with a constant retarding ratio. If the analyzer is operated at a constant pass energy, specify the energy resolution used on the right line.

 Or

 in %(constant) in eV (constant pass)
- 9. Analyzer Constants Enter either the relarding ratio used in the measurement or the pass energy, in eV, used.

 Retard Ratio

 Pass Energy (eV)

For fields 10-11 below, the x and y axes are $\ensuremath{^{16}}$ axes defined on the scattering geometry figure from Section C.

10. Analyzer Widths - Enter the size, in µm, of the analyzer entrance slit image projected onto the specimen surface. This is the analyzer "field of view" expressed in terms of the dimensions of the region on the specimen being analyzed, which maybe energydependent. If energydependent, enter the electron energy at which the widths were measured.

Was the analyzer width energy-dependent? ☐ No

2000 2000 | 1000

X Value (pm) Y Value (μm) of Energy (eV)

11. Analyzer Angular Acceptance Width — Indicate if the analyzer angle of acceptance is constant. Due to fundamental electron optics, the field of view and acceptance angle cannot both remain constant. Specify the angle subtended by the analyzer entrance aperture os determined in the x and y directions (for cylindrically symmetric apertures, they will be the same value). Enter N/A for a CMA. Non-standard parameters should be described in Field 4, Section C. If energy-dependent, enter the electron energy at which the

angular occeptonce was measured.

Was the analyzer angular acceptance angle constant with energy?

Yes No

No

X Angle (degrees)

Y Angle (degrees)

at Energy (eV)

E. Variable instrument Parameters

Complete a CODY of this section for each set of instrument settings. For example, you might-be contributing survey SCANS that have different energy resolutions, SCON rates, etc. from a high-resolution scan of a transition' lineshape. The first field allows you to give each set of instrument settings a number for referencing to specific spectra. You need to complete a copy of this section for each different set.

1. Parameter Set # - Enter an identifying serial number, starling with "1" for this ser of variable instrument parameters. These numbers will be used in the individual data records to reference the appropriate parameter set for each spectrum described in Section1.

Source **Operating** Parameters

2. Source Energy - Enter the characteristic energy (in e V) of the excitation source, e.g. 5,000 eV for a 5 keV electron beam, 1486.6 eV for AI Ka, 1253.6 eV for Mg KQ, etc.

486 6

3. Source Strength Value and Units — Enrer the strength of the excitation source and the correct corresponding units. Far XPS, this could be anode power in Watts or radiation flux density on the specimen in photons/mm² sec or, for electron beams, noncomps or nanoamps/mm².

Strength Value

4. Source Beam Size - list the x and y values for the unscanned excitation source size. Choose the x and y axes to coincide with the manufacturer definitions. If the beam is cylindrically symmetric, x and y are equal. In other cases, such as the HP ESCA system, the beam is not cylindrically uniform, in choosing the axes, insure that x anti y are onhogonal to each other aria' to the excitation source

X Value(µm)

3 i 5. Source Raster

Yes

XI No

6. Source Size - Enter the x and y dimensions, in μm, of the excitation beam of the specimen surface. Note that this can differ from the source beam size enterect previously by virtue of beom rastering or non-normal angle of incidence on the specimen, or both.

.300 Υ (μmi

- 7. Raster Frame Rate Give the time interval required to return the beam to a given spot on the sample (in Hertz) if the source is scanned over the sample.
- 8. Analyzer Resolution Enter the percent energy resolution used in the measurement on the left line if the analyzer is operated with a constant retarding ratio. I/the analyzer is operated at a constant pass energy, specify the energy resolution used on the right line.

0.25 in % (constant retarding ratio)

9. Analyzer Constants - Enter either the retarding ratioused in the measurement or the pass energy, in eV, used. 25--Pass Energy (eV) Retard Ratio

For fields 10-11 below, the x and y axes are he axes defined on the scattering geometry figure from Section C.

3 10. Analyzer Widths - Enter the size, in µm, of the analyzer entrance slit image projected onto the specimen surface. This is the analyzer "field of view" expressed in terms of the dimensions of the region on the specimen being analyzed, which may be energy-dependent. If energy-dependent, enter the electron energy at which the widths were measured.

Was the analyzer width energy-dependent? XYes

<u>2000</u> _ <u>≥000</u> X Vaiue (μm) Y Value (μm)

E. Variable Instrument Parameters

❸ 11. Analyzer	Angular Acceptance Width -	Indicate if the analyzer angle of acceptance is constant. Due to fundamental electron optics, the field of view and acceptance angle cannot both remain constant. Specify the angle subtended by the analyzer entrance aperture as determined in the x and y directions (for cylindrically symmetric apertures, they will be the same value). Enter N/A for a CMA. Non-standard parameters should be described in Field d, Section C. If energy-dependent, enter the electron energy at which the
		Section C. If energy-dependent, enter the electron energy at which the angular accertance was measured.

Was the analyzer angular acceptance angle	constant with energy?	X Yes		No	
<u> 30</u> _	30				الموساء ومعروب المنف
X Angle [degrees]	Y Angle [degrees)		at	Energy	(eV)

E Variable Instrument Parameters

Complete a copy of this section for each set of instrument settings. Far example, you might be contributing survey scans that hove different energy resolutions, scan rates, etc. from a high-resolution scan of a transition's lineshape. The first field allows you to give each set of instrument settings a number for referencing to specific spectra. You need to complete a copy of this section for each different set.

0	1. Parameter Set # - Enter an identifying serial number, starring with "I" for this set of variable instrument parameters.
-	These numbers will be used in the individual data records 10 reference the appropriate parameter set
	for each spectrum described in Section i.

Source Operating Parameters

1 2. Source Energy - Enter the characteristic energy (in e V) of the excitation source, e.g. 5,000 eV for 05 keV electron beam, 1486.6 eV for Al Ka, 1253.6 eV for Mg Kα, etc.

1486.6

3. Source Strength Value and Units - Enter the strength of the excitation source and the correct corresponding units.

For XPS, this could be anode power in Watts or radiation flux density on the specimen in photons/mm² sec or, for electron beams, nanoamps or nanoamps/mm².

100

Strength Value

way.

Units

4. Source Beam Size - list the x and y values for the unscanned excitation source size. Choose the x and y axes 10 coincide with the manufacturer definitions. If the beam is cylindrically symmetric, x and y are equal. In other cases, such as the HPESCA system, the beam is not cylindrically uniform. In choosing the axes, insure that x aria' y ore orthogonal to each other aria' to the excitation source axis.

600

600

X Value (μm)

Y Value (pm)

3 5. Source Raster

Yes

X No

6. Source Size - Enter the x and y dimensions, in \(\mu m \), of the excitation beam at the specimen surface. Note that this can differ from the source beam size entered previously by virtue of beam rastering or non-normal angle of incidence on the specimen, or both.

1046 600 χ(μm) γ(μm)

- 7. Raster Frame Rate Give the time interval required to return the beam to a given spot on the sample (in Hertz) if the source is scanned over the sample.
- 8. Analyzer Resolution Enter the percent energy resolution used in the measurement on the left line if the analyzer is operated with a constant retarding ratio. If the analyzer is operated at a constant pass energy, specify the energy resolution used on the right line.

in % (constant retarding ratio)

Or

in eV (constant poss)

9. Analyzer Constants – Enter either the retarding ratio used in the measurement or the pass energy, in eV, used.

Or
Retard Ratio

Pass Energy (eV)

For **fields 10-11** below, the x and y axes are **the** axes **defined on the scattering** geometry figure from **Section** C.

• Enter the size, in µm, of the analyzer entrance slit image projected onto the specimen surface. This is the analyzer "field of view" expressed in terms of the dimensions of the region on the specimen being analyzed, which may be energy-dependent. If energy-dependent, enter the electron energy at which the widths were measured.

E. Variable Instrument Parameters

	T
Ull. Analyzer Angular Acceptance Wid	dth - Indicate if the analyzer angle of acceptance is constant. Due to
•	fundamental electron optics, the field of view ond acceptance angle
	cannot both remain constant. Specify the angle subtended by the
	analyzer entrance aperture as determined in the x and y directions (for
	cylindrically symmetric apenures, they will be the same value). Enter N/A
	Far a CMA. Non-standard parameters should be described in Field A,
	Section C If energy-dependent, enter the electron energy at which the
	angular acceptance was measured

Wers the analyzer angular acceptance angle con	stant with energy?	X Ye	s 🗇	No	
_30	_30 _				
X Angle (degrees!	Y Angle (degrees)		at E	nergy (eV)	

F. Spectrum Parameters

Complete a copy of this section for each spectrum, including calibration spectra, submitted in this data record.

- O | 1. Spectrum # Number the spectra in the data record serially from 1. Enter the number of this spectrum.
- Suggested Publication Status of this spectrum

Print in Surface Science Spectro

Enter in AVS electronic database only

O 3. Spectrum Filename - Enter the filename of this spectrum as designated on the magnetic media submitted.

CuC12-1

0 4. Is this a Calibration Spectrum?

☐ Yes

💹 No

Parameter Set # to Use - Provide the number identifier (Field 1, Section E) for the set of instrument parameters used to measure this spectrum.

3 Date - Enter the date that the spectrum for this region was measured. The format is YYYYMMDD.

7. Species Label - Provide the symbol for the element being measured in this spectral region, e.g. Cl, N, etc. More than one element may be represented. 1//his is a survey spectrum, enter "survey."

Survey _

8. Transition Label - Record the core-level transition that is producing this spectrum, e.g. "Kll" for AES, "2p" for XPS, etc. list the corresponding transitions in the some order as you listed the elements in Field 7 above. If the spectrum is o survey scan, enter "survey."

Survey

- 9. Spectral Region Comment Enter comments describing the spectrum more fully when the element and transition do not adequately characterize the spectrum. For example, provide information about critical experimental variables (temperature, etc.) that should be emphasized or provide comments on the identification of peaks arising (rem multiple chemical states, satellites, interference between peeks, etc. in the spectrum.
- 10. Abscissa Label Check the appropriate box for the energy axis.
 - ☐ Kinetic Energy 🕱 Binding Energy
- 11. Abscissa Values Enter the energy, in eV, of the first data point displayed on the left in the spectrum plot and the energy increment, in eV/channel, used in the energy scan of this spectrum. For display purposes, Auger kinetic energies will increase from left to right (positive increment value), and XPS binding energies will decrease going from left to right (negotive increment value).

- 112. Ordinate Label Specify they axis label, such os intensity, etc.
- 13. Ordinate Units Specify the units of signal in each channel, such as "arbitrary units," "counts," "counts/see," etc.
- 14. Number of Data Channels Specify the number of channels used to measure the spectrum.
- 2 15. Number of Scans Specify the number of times the signal for a given channel was counted.

	for single-channel pulse of	counting; multichannel dire	tized using an analog-to-dig ect for analog measurement net detector with photon col	using a position-sensitive
Direct Analog	☐ V/F Analog	Pulse Single Channel	Multichannel Direct	Multichannel Indirect
Equivalent Simult			channel detector. For a muli n the spectrum covered by th	
8. Seconds per Sc	an – Enter the time need	ded for one scon in second	ds.	
9. Total Seconds th		rd the total elapsed time u	sed to acquire this spectrum	n in seconds.
<u> </u>				
	- Record your 'system taunt rate by	(1- dead	value, the count rote shoul time) x (time/channel)	ld be corrected by dividin
	- Record your 'system	(1- dead , the correction is	time) x (lime/channel)	ld be corrected by dividin
	- Record your 'system taunt rate by	(1- dead , the correction is		ld be corrected by dividin
O. Time Correction	n - Record your 'system taunt rate by For a negative value on Method - Check module	(1- dead , the correction is exp. (measured the appropriate field for	time) x (lime/channel) I count rate) x (deed time) the signal modulation. Desc Section H. Note that only "ra	ribe any tailored
O. Time Correction	n - Record your 'system taunt rate by For a negative value on Method - Check module	(1- dead the correction is exp. (measured the appropriate field for a	time) x (lime/channel) I count rate) x (deed time) the signal modulation. Desc Section H. Note that only "ra	ribe any toilored aw" data, not computer-
O. Time Correction None None	on Method - Check moduli (sinusoidal modulation/	(1- dead the correction is exp. (measured the appropriate field for a ation function in Field 2, a nitiated date, should be so Tailored (using special modulation function)	time) x (lime/channel) I count rate) x (deed time) the signal modulation. Desc Section H. Note that only "rate of the control of the contro	eribe any toilored aw" data, not computer- g Beom Amplitude (modulated

Page 19

F. Spectrum Parameters

AES/XPS Contributors Farm

F. Spectrum Parameters

Complete a copy of this section for each spectrum, including calibration' spectra, submitted in this data record.

1. Spectrum # - Number the spectra in the data record serially from 1. Enter the number of this spectrum.

2

1 2. Suggested Publication Status of this **Spectrum**

Print in Surface Science Spectra

Enter in AVS electronic darabase only

3. Spectrum Filename - Enter the filename of this spectrum os designated on the magnetic media submitted.

_CuCl2_2

0 [4. Is this a Calibration Spectrum?

Yes

Ø N∘

5. Parameter Set # to Use - provide the number identifier (Field 1, Section E) for the set of instrument parameters used to measure this spectrum.

<u>2</u>

6. Date -- Enter the dote that the spectrum for this region was measured. The format is YYYYMMDD.

19890202

7. Species Lab?rovide the symbol for the element being measured in this specifal region, e.g. Cl. N. etc. More than one element may be represented". 1/this is a survey spectrum, enter "survey."

Cu

8. Transition Label — Record the core-level transition that is producing this spectrum. e.g. "KU" for AES, "2P" for XPS, etc. List the corresponding transitions in the same order as you listed the elements in field 7 above. If the spectrum is a survey scan, enter "survey."

2 P3/2 _____

F. Spectrum parameters

9. Spectral Region Comment - Enter comments describing the spectrum more fully when the element ond transition do not adequately characterize the spectrum. For example, provide information about critical experimental variables (temperature, etc.) that should be emphasized or provide comments on the identification of peaks arising from multiple chemical states, satellites, interference between peaks, etc. in the spectrum.

.0110. Abscissa Label - Check the appropriate box for the energy axis.

☐ Kinetic Energy 🖾 Binding Energy

11. Abscissa Values - Enter the energy, in eV, of the first doter point displayed on the left in the spectrum plot and the energy increment, in eV/channel, used in the energy scan of this spectrum. For display purposes, Auger kinetic energies will increase from left to right [positive increment value], and XPS binding energies will decrease going from left to right (negative increment value).

948,9 — O, 156 "
Starting Value Increment Value

0112. Ordinate Label - Specify they axis label, such os intensity, etc.

Xntensity

- 0113. Ordinate Units Specify the units of signal in each channel, such os "arbitrary units," "counts," "counts," eec," etc.
- 14. Number of Data Channels Specify the number of channels used to measure the spectrum.
- 20 15. Number of Scans Specify the number or times the signal for a given channel was counted.

0	16.	Signal Mode -	that is then digitized; V/F for single-channel pulse co	or on analog signal digit ounting; multichannel dire	uistion mode: direct for on an ized using an analog-to-digite ct for analog measurement us el detector with photon conve	ol converter; pulse single sing a position-sensitive
		Direct Analog	☐ V/F Analog	Pulse Single Channel	Multichannel Direct	Multichannel Indirect
0	1 <i>7</i> .	Equivalent Sim		 Enter "I" for a single-c number of channels in 	hannei detector. For a multion the spectrum covered by the	channel detector, enter the width of the detector.
0	18.	Seconds per \$	can - Enter the time need	ed for one scan in second	ris.	
0	19.	Total Seconds		d the total elapsed time u	ised to acquire this spectrum i	in seconds.
•	20.	Time Correction	- Record your "system d count rote by For a negative value,	(1- dead ti	value, the taunt rate should	be corrected by dividing
		None			l count rate) x (dead lime)	
О	[21.	Signal <i>I</i> Undulat	modula		he signal modulation. Describ Section H. Note that only "rav bmitted.	
		⊠ None	Sinusoidal (sinusoidal modulation/ demodulation)	Tailored (using special modulation function)	3eam Blanking (chopped beam modulation)	Beam Amplitude (modulated beam strength)
9	22.	lock-in Parame	ters - Complete only if a	ppropriate.		
		Peak-to-peak ampli		lation frequency of erence signal in (Hz)	Time constant of the amplifierused in se	

F. Spectrum Parameters

Complete a copy of this section for each spectrum, including calibration spectra, submitted in this data record.

1. Spectrum # - Number the spectra in the data record serially from 1. Enter the number of this spectrum.

3

1 2. Suggested publication Status of this Spectrum

Print in Surface Science Spectra

- Enter in AVS electronic database only
- 1 3. Spectrum Filename Enter the filename of this spectrum as designated on the magnetic media submitted.

Cuc12-3

1 4. Is this a Calibration spectrum?

☐ Yes

Ø No

5. Parameter Set # to Use - Provide the number identifier (Field), Section E) for the set of instrument parameters used. to measure this spectrum.

2

6. Date - Enter the date that the spectrum for this region was measured. The format is YYYYMMDD.

19890202

7. Species Label - Provide the symbol for the element-being measured in this spectral region, e.g. Cl., N, etc. More than one element may be represented. If this is a survey spectrum, enter "survey."

C. I

8. Transition Label — Record the core-level transition that is producing this spectrum, e.g. "KLL" for AES, "2p' for XPS, etc. list the corresponding transitions in the some order as you listed the elements in Field 7 above. If the spectrum is a survey scan. enter" survey."

-2p_____

F. Spectrum Parameters

0	9. Spectral Region Comment -	Enter comments describing the spectrum more fully when the element and transition do
		not adequately characterize the spectrum. For example, provide information about
		critical experimental variables (temperature, etc.) that should be emphasized or
		provide comments on the identification of peaks arising L-em multiple chemical states,
		satellites, interference between peaks, etc. in the spectrum.

. 0 1 1 0 . Abscissa Label - Check the appropriate box for the energy oxis.

☐ Kinetic Energy 🖾 Binding Energy

Counts

• Enter the energy, in eV, of the first data point displayed on the left in the spectrum plot and the energy increment, in eV/channel, used in the energy scan of this spectrum. For display purposes, .-luger kinetic energies will increase from left to right (positive increment value), and XPS binding energies will decrease going from left to right (negative increment value).

208.9 -0.117
Starting Value Increment Value

12. Ordinate Label - Specify they axis label, such as intensity, etc.

0113. Ordinate Units – Specify the units of signal in each channel, such as "arbitrary units, " "counts," "counts/sec," etc.

- 14. Number of Data Channels Specify the number of channels used to measure the spectrum

 128
- 2 0

16. Signal Mode -	that is then digitized: V/F for single-channel pulse c	x to identify the data acq for an analog signal digit counting; multichannel dire al indirect for a multichan	tized using ar ect far analog	n analog-lo-digi measurement us	lal converter; pulse sing sing a position-sensitive
Direct Analog	□ V/F Analog	Pulse Single Channel		Multichannel Direct	, Multichonnel Indirect
17. Equivalent Simu					tichannel detector, enter ewidth of the detector,
18. Seconds per Sc _ 6 <u>0</u>	an - Enter the time need	ded for one scan in second	ds.		
19.Total Seconds th		era' the total elapsed time	used to acqui	ire this spectrum	n in seconds.
20. Time Correction	— Record your "system count rate by		e value, the t		d be corrected by dividia
	For a negative value	e, the correction is			
None		exp. (measured	d count rate)	x (dead time)	
21. Signal Modulat	modul	the appropriate field for a ation function in Field 2, S antiated data, should be su	ection H. No	odulation. Descr te that only "ra	ibe any tailored w" data, not computer-
⊠ None	Sinusoidal (sinusoidal modulation/ demodulation)	Tailored (using special modulation function)	(ch	m Blanking opped beam dulation)	Beam Amplitude (modulated beam strength)
22. lock-in Paramet	ers – Complete only if c	appropriale.			
Peak-to-peak amplite the modulation in e		uiation frequency of eference signal in (Hz)		neconstantofth polifierused in s	

F. Spectrum Parameters

Complete a copy of this section for each spectrum, including calibration spectra, submitted in this data record.

- 1. Spectrum # Number the spectra in the data record serially from 1. Enter the number of this spectrum.
- 2. Suggested publication Status of this Spectrum

 Print in Surface Science Spectra

 Enter in AVS electronic database only
- 3. Spectrum Filename Enter the filename of this spectrum as designated on the magnetic media submitted'.
- 4. Is this a Calibration Spectrum?Yes ☒ No
- Parameter Set # to Use Provide the number identifier (Field 1, Section E) for the set of instrument parameters used to measure this spectrum.
- 6. Date Enter the date that the spectrum for this region was measured. The formal is YYYYMMDD.
- 7. Species Label Provide the symbol for the element being measured in this spectral region, e.g. Cl., N. etc. More than one element may be represented. If this is a survey spectrum, enter "survey."
- 8. Transition Label Record the core-level transition that is producing this spectrum. 3. g. "KL1" for AES, "2p" for XPS, etc.

 List the corresponding transitions in the same order as you listed the elements in field 7 above. If the spectrum is a survey scan. enter 'survey.'

 LMM

9. Spectra: Region Comment - Enter comments describing the spectrum more fishy when the element and transition do not adequately characterize the spectrum. Far example, provide information obout critical experimental variables (temperature, etc.) that should be emphasized or provide comments on the identification of peaks arising from multiple chemical states, satellites, interference between peaks, etc. in the spectrum.

.0110. Abscissa Label - Check the appropriate box for the energy axis.

☐ Kinetic Energy 🛭 Binding Energy

11. Abscissa Values - Enter the energy, in eV, of the first data point displayed on the left in the spectrum plot and the energy increment, in eV/channel, used in the energy scan of this spectrum. For display purposes, Auger kinetic energies will increase from left to right (positive increment value), and XPS binding energies will decrease going from left to right (negative increment value).

591,9 -0, 195_ Starting Value Increment Value

12. Ordinate Label - Specify the y axis label, such as intensity, etc.

13. Ordinate Units - Specify the units of signal in each channel, such as "arbitrary units, "counts," "counts," etc.

- 14. Number of Data Channels Specify the number of channels used to measure the spectrum.

 2.56

Í	SU	RFACE SCIEI	NCE SPECTRA	F. Spectrum Paramete			
0	16.	Signal Mode -	Check the appropriate box that is then digitized; V/F for for single-channel pulse cou detector; and multichannel	r an analog signal digitiz Inting; multichannel direc	zed using an analog-to-d e ct for analog measuremen	igilal converter; pulse single it using a position-sensitive	
		☐ Direct Analog	☐ V/F Analog	U Pulse Single Channel	Multichanne Direct	il .Multichannel Indirect	
0	17.		nultaneous Channels -			ultichannel detector, enter the the width of the detector.	
0	18.	Seconds per \$	can - Enterthe time neede	d for one scan in second	is.		
0	19.	Total Seconds t	this Spectrum – <i>Record</i>	l the total elapsed time u	sed/o acquire this spectro	um in seconds.	
4	20.	Time Correctio	n∩ – Record your *system de count rate by		value,the count rate sho	uld be corrected by dividing	
			For a negative volue,	he correction is			
		None		exp.(measured	count rate; x (dead time)		
0	21.	Signal Modula			Section H. Note that only	scribe any tailored "raw" data, not computer-	
		None	Sinusoidal " (sinusoidal modulation/ demodulation)	Tailored (using special modulation function)	1 3eom Blanking (chopped beom modulation)	Beam Amplitude (modulated beam strength)	
9	22.	Lock-in Parame	ters – Complete only if an	propriate.			

Modulation frequency of

the reference signal in (Hz)

Time constant of the lock-in

amplifier used in seconds

Peak-to-peak amplitude of

the modulation in eVornA

LF. Spectrum Parameters

Complete a copy of this section for **each** spectrum, including calibration spectra, submitted in this data record.

1. Spectrum # - Number the spectra in the dots record serially from 1. Enter the number of this spectrum.

5

1 2. Suggested Publication Status of this Spectrum

Print in Surface Science Spectra Enter in AVS electronic database only

3. Spectrum Filename - Enter the filename of this spectrum as designated on the magnetic media submitted.

Cucl2-5

0 [4. is this a Calibration Spectrum?

5. Parameter Set # to Use - Provide the number identifier (Field 1, Section E) for the set of instrument parameters used to measure this spectrum.

3

3 6. Date -- Enter the date that the spectrum for this region was measured, The format is YYYYMMDD.

19890202

7. Species Label - Provide the symbol for the element being measured in this spectral region, e.g.Cl, N, etc. More than one element may be represented. 1/this is a survey spectrum, enter "survey."

C_

8. Transition Label — Record the core-level transition that is producing this spectrum. e.g. "KU" for AES. "2p' for XPS, etc. List the corresponding transitions in the some order as you listed the elements in Field 7 above. If the spectrum is a survey scan, enter "survey."

<u>1 s</u>

- 9. Spectral Region Comment Enter comments describing the spectrum more Lilly when the element and transition do not adequately characterize the spectrum. For example, provide information about critical experimental variables (temperature, etc.) that should be emphasized or provide comments on the identification of peaks arising from multiple chemical states. satellites, interference between peaks, etc. in the spectrum.

,0110. Abscissa Label - Check the appropriate box for the energy axis.

- ☐ Kinetic Energy 🖾 Binding Energy
- 11. Abscissa Values Enter the energy, in eV, of the first data point displayed on the left in the spectrum plot and the energy increment, in eV/channel, used in the energy scan of this spectrum. For display purposes, Auger kinetic energies will increase [rem left to right (positive increment value), and XPS binding energies will decrease going from left to right (negative increment value).

294,9 -0,117 Starting Value

12. Ordinate Label - Specify they axis label, such as intensity, etc.

Intensity

- 13. Ordinate Units Specify the units of signal in each channel, such os "arbitrary units," "counts," "counts/see," etc. Count s
- 14. Number of Data Channels Specify the number of channels used to measure the spectrum. _ 12.8

2 15. Number of Scans - Specify the number of times the signal for a given channel was counted.

2 16.	16. Signal Mode - Check the appropriate box to identify the data acquistion mode: direct for an analog signal measurement that is then digitized; V/F for an analog signal digitized using an analog-to-digital converter; pulse sing for single-channel pulse counting; multichannel direct for analog measurement using a position-sensitive detector; and multichannel indirect far a multichannel detector with photon conversion.									
	Direct Analog	☐ V/F Analog	Pulse Single Channel	Multichannel Direct	Multichannel Indirect					
. 0117. Ed	quivalent Simul			channei detector. For o m n the spectrum covered by t	ultichannel detector, enter the the width of the detector.					
2 18.	Seconds per So	can - Enter the time neede	d for one scon in second	ds.						
2 19.	Total Seconds t	his Spectrum – Record	d the total elapsed time u	ised to acquire this spectru	m in seconds.					
4 20.	Time Correction	count rate by	[1- deed ti	value, the count rate shou	uld be corrected by dividing					
		For a negative volue,								
	None		exp. (measured	count rate) x (dead time)						
0121.	Signal Modulati			Section H. Note that only "I	-					
	None .	☐ Sinusoidal	Tailored	3eam Blanking	Beam Amplitude					
	_	[sinusoidal modulation/ demodulation)	(using special modulation function)	(chopped beam modulation)	(modulated beam strength)					
Q 22.	Lock-in Parame	ters – Complete only if ap	ppropriate.							
	Peak-to-peak amplitu		ation frequency of erencesignal in (Hz)		Time constant of '! ehlack-in amplifier used in seconds					

H. Analysis Methods

=143 33	e.Refer	enced	<u>to</u> th e.	adventitious	hydro car	bon <u>C</u> 1s
at	284.	6	eV	- Marie and Marie and American	4,4,0	and the second s
	<u> </u>			Applications against an executive the green subject to their amounts to the parameters.		
Inter	nsity Scale (Correction	On - Discuss any	function opplied to the	e spectral intensities to	o adjust ine peak ampi
	nsity Scale (Correction	on – Discuss any reported.	function applied to the	e spectral intensities to	o adjust ine peak ampi

3. peak Shape and Background Methods – Describe the technique used for background correction, e.g. linear subtraction, Shirley function, Tougoard function, Fourier transform cutciff, etc. Describe the procedure used to fit the spectral lineshape, e.g. Gaussian, Lorentzian, Voight, Doniach-Sunjic, etc., and to measure peek amplitude.

Shirley background subtraction is used in the least squares
fitting, Peak positions and widths are determined from least squares
fitting using the standard SSI software. The peak shape is fixed
to a mix of 80% Gaussian - 20% Lorentzian with an asymmetry
parameter of 0.

4. Quantitation Method — Specify the method used to determine the values for the atomic concentrations for the analyzed region. Please cite references for the quantitation method in the bibliography (refer to Field 11, Section A).

Sensitivity factors are from the standard SSI software. The peak areas are the areas above a linear background. The composition was culculated using the standard SSI software, using the intensities measured in the survey scan.

/. Spectral Features Descriptions

0	1. /	Major Elements	- List the principal eleme	nis identified in the spect	ra submitted in this recor	d.
		<u> </u>				•
	_					
0	2.	Minor Elements	 List the trace elements 	identified that appear in th	he spectra in this record.	
		. <u>C</u> .				and the state of t
	The	following three fi	elds define the qua	ntitative portions	of the feature tabl	e on the next page.
_	ı					
0	3.	. Peak Amplitude	Method			
		Peak Height'	🛛 Peak Area			
•	١.	,				
6	4	. peak Amplitude	Units			
A service		☑ Total Counts	☐ Counts/see	Normalized to o selected peed intensity	□ eV x counts e k	eV x counts/see
_						
0	5.	Concentration U	nits			
		Atomic%	Weight%	☐ Monolayers	mg/m²	Other

[. Spectral Features Descriptions

Place of Spectral Features — Enter in the table below all the transitions identified in the spectra. Use care to enter the appropriate number of significant figures. (For example, the entry 283.2 is not the same os 283.20.1 If desired, the computed uncertainty may be entered with o value (e.g., 283.20 ± 0.05). The peak amplitude method and units for peak amplitude and concentration are those entered on the previous page. The sensitivity factors are those used for the transition in the quantilation, and the last column is for a brief comment on the peek assignment, e.g. carboxylate, Mo(IV), etc.

Spectrum ID#	Element, Transition	Peak Energy, eV	Peak Width (FWHM), eV	Peak Amplitude	Sensitivity Factor	Concentration	peak Assignment
1+2	Cu 2p3/2	? 3 4 ? 7	2.0	45423	9,748	33. ?	
1+3	C12p	198,9	1.5	21 750	2 ,395	66.1	Position is the Zpz.
4	CuL3 Mys Mus	570.9					
_					1		
			<u> </u>			<u> </u>	
		1					

Note: For purposes of labeling transitions in the published spectra, please annotate the submitted hard copy spectra with alphanumeric peak identifications as you would like them to appear.

Append/x: Contributors' Comments

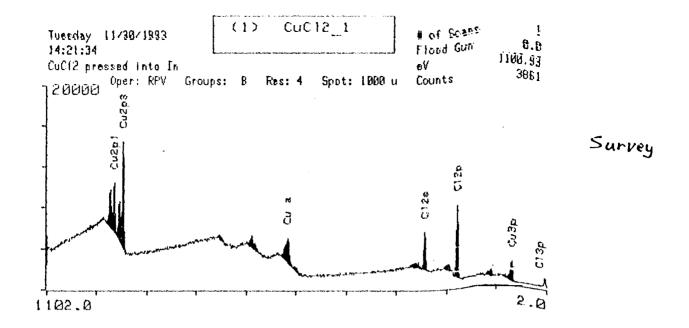
Comments for the Editors -	Please add any comments or suggestions you might hove concerning this form or Surface Science Spectra. We value your feedback.	
Backey makes I		

Checklist - A complete submission must include the following:

- Completed AES/XPS Contributors Form (3 copies).
 - Herd copies of all spectra (3 copies).
 - Digitized spectra on magnetic disk.

Record the disk characteristics below:

End of the AES/XPS Contributors Form.



SURFACE COMPOSITION TABLE CuC12_1
CuC12pressed into In

Elem	Corr'd Flood BE Gun	Delta BE	Sens Factor	# of Scans	eV/ proup_	Area <u>Area</u>	Relative —	Atom
Cu2p3 C12p	935.24 0.0 198.91 0 .0				1 3 7 . 5 137.s	45423 21750	500575 975502	•

